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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/564,915	01/17/2006	Johannes Hendrikus Maria Spruit	NL030943	5359
7590 03/19/2008 Corporate Patent Counsel			EXAMINER	
Philip Electronics North America Corporation P.O. Box 3001 Briarcliff Manor, NY 10510			PENDLETON, DIONNE	
			ART UNIT	PAPER NUMBER
	,		2627	
			MAIL DATE	DELIVERY MODE
			03/19/2008	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

Application No. Applicant(s) 10/564,915 SPRUIT ET AL.

Office Action Summary	Examiner	Art Unit				
	DIONNE H. PENDLETON	2627				
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply						
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DY Estensions of time may be available under the provisions of 3 CFR 1.1 after SIX (6) MONTHS from the mailing date of this communication. If NO prince of rengly is generalled above, the macrimum statutory period we have a considered above. The macrimum statutory period was a first the macrimum statutory period was a first through the control of	ATE OF THIS COMMUNICATION 16(a). In no event, however, may a reply be tin till apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	N. nely filed the mailing date of this o D (35 U.S.C. § 133).	,			
Status						
1) Responsive to communication(s) filed on 17 Ja	nuary 2006.					
2a) This action is FINAL. 2b) ☑ This	2a) ☐ This action is FINAL . 2b) ☑ This action is non-final.					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is						
closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims						
4) Claim(s) 1-6 is/are pending in the application.						
4a) Of the above claim(s) is/are withdrawn from consideration.						
Claim(s) is/are allowed.						
6)⊠ Claim(s) <u>1-6</u> is/are rejected.						
7) Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction and/or	election requirement.					
Application Papers						
9) The specification is objected to by the Examine	r.					
10)⊠ The drawing(s) filed on 17 January 2006 is/are: a)⊠ accepted or b)□ objected to by the Examiner.						
Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).						
Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).						
11) The oath or declaration is objected to by the Ex	aminer. Note the attached Office	Action or form P	ΓO-152.			
Priority under 35 U.S.C. § 119						
12)⊠ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a)⊠ All b)□ Some * c)□ None of:						
1. Certified copies of the priority documents have been received.						
Certified copies of the priority documents have been received in Application No						
Copies of the certified copies of the prior	•	ed in this National	Stage			
application from the International Bureau						
* See the attached detailed Office action for a list	of the certified copies not receive	d.				
Attachment(s)						
1) Notice of References Cited (PTO-892)	4) Interview Summary	(PTO-413)				
2) Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail Da 5) Notice of Informal P	ate				

Attachment(s)		
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/95/08)	4) Interview Summary (PTO-413) Paper No(s)/Mail Date. 5) Notice of Informal Pater LApplication 6) Other:	
Paper No(s)/Mail Date	o) Culer	

Art Unit: 2627

DETAILED ACTION

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

 Claims 1-6 are rejected under 35 U.S.C. 102(b) as being anticipated by Fukumoto (US 2003/0086346).

Regarding claim 1,

Fukumoto teaches a method for setting an optimal value of a write power level of a radiation beam for use in an optical recording apparatus for writing information on an optical recording medium (20), the information being written on the optical recording medium by applying the radiation beam to the optical recording medium, the method comprising a first step ("S28" in figure 2) of writing a series of test patterns in a test area on the optical recording medium, each test pattern written with a different value of the write power level of the radiation beam, a second step ("S30") of reading the written test patterns to form corresponding read signal portions, and a third step ("S36") of selecting the optimal value (Px; also see [0042]) of the write power level in dependence on the read signal portions, characterized in that in the first step the series of test patterns are written at a low recording speed (V1: also see [0041]:lines 5-8).

Art Unit: 2627

and that in the third step the optimal value of the write power level at a high recording speed (Vx) is selected in dependence on the read signal portions and on a parameter indicative of the relation (β) between the value of the write power level at the high recording speed (Vx) and the value of the write power level at the low recording speed (Vx) and the value of the write power level at the low recording speed (Vx) and the value of the write power level at the low recording speed (Vx) and the value of the write power level at the low recording speed (Vx) and Vx).

Regarding claim 2,

Fukumoto teaches a method according to claim 1, wherein the parameter indicative of the relation between the value of the write power level at the high recording speed and the value of the write power level at the low recording speed (P.high/P.low) is read from the recording medium ([0028-0030] teach ATIP parameters used to generate a β value, said value used in determining OPL at high speed, given OPL at low speed; also see [0042-0043]).

Regarding claim 3,

Fukumoto teaches an optical recording apparatus for recording information on an optical recording medium (20) comprising a radiation source ("LD" in pickup "28") for emitting a radiation beam for recording information on the recording medium, the radiation beam having a controllable value of a write power level, a control unit (24) operative for recording a series of test patterns in a test area in the recording medium ([0006]), each pattern with a different value of the write power level, a read unit (30) for reading the recorded test patterns and for forming corresponding read signal portions, and setting means ("\$30" in Figure 2) for setting an optimal value of the write power

Art Unit: 2627

level in dependence on the read signal portions, characterized in that the control unit (24) is operative for recording the series of test patterns in the test area in the recording medium at a low recording speed ("V1"; see "S28" in Figure 2), and in that the setting means ("S36" in Figure 2) are operative for setting an optimal value of the write power level at a high recording speed in dependence on the read signal portions and on a parameter indicative of the relation between the value of the write power level at the high recording speed and the value of the write power level at the low recording speed (paragraphs [0041-0042]).

Regarding claim 4,

Fukumoto teaches an apparatus according to claim 3, wherein the read unit is operative for reading the parameter indicative of the relation between the value of the write power level at the high recording speed and the value of the write power level at the low recording speed (P.high/P.low) from the recording medium ([0028-0030] teach ATIP parameters used to generate a β value, said value used in determining OPL at high speed, given OPL at low speed; also see [0042-0043]).

Regarding claim 5,

Fukumoto teaches an optical recording medium comprising an area ("ATIP") comprising recording parameters indicative of the recording process, said area comprising a parameter indicative of the relation between the value of the write power level at the high recording speed and the value of the write power level at the low recording speed (see, parameters used to generate β value; also see [0043]

Art Unit: 2627

wherein Fukumoto teaches that β is indicative of relation between power and recording speed).

Regarding claim 6,

Fukumoto teaches an optical recording medium according to claim 5, wherein the parameter is related to P.high/P.low, where P.high ("Vx") is the optimum write power level at a high recording speed and P.low ("Vi") is the optimum write power level at the OPC velocity (paragraphs [0041-0042]).

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to DIONNE H. PENDLETON whose telephone number is (571)272-7497. The examiner can normally be reached on 10:30-7:00 M-F.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wayne Young can be reached on 571-272-7582. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Application/Control Number: 10/564,915 Page 6

Art Unit: 2627

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Dionne H Pendleton/ Examiner, Art Unit 2627

/Wayne R. Young/ Supervisory Patent Examiner, Art Unit 2627